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	Application No.	Applicant(s)
Notice of Allowability	10/710,001	MO ET AL.
	Examiner	Art Unit
	Stanetta D. Isaac	2812
The MAILING DATE of this communication appeal All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in the or other appropriate communities. This application is sub-	nis application. If not included cation will be mailed in due course. THIS
1. This communication is responsive to the Ex parte Quayle is	filed on 2/6/06.	
2. The allowed claim(s) is/are <u>1-22</u> .		
<ul> <li>3. Acknowledgment is made of a claim for foreign priority uses a) All b) Some* c) None of the: <ol> <li>Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 1. Copies of the certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 3. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 3. Copies of the priority documents have 3. Certified copies of the priority documents have 3.</li></ol></li></ul>	e been received. e been received in Application cuments have been received in the file a	No  In this national stage application from the
4. A SUBSTITUTE OATH OR DECLARATION must be subministration (PTO-152) which give		
<ul> <li>5.  CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date</li> <li>(b) including changes required by the attached Examiner' Paper No./Mail Date</li> <li>Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the deposition of the deposit</li></ul>	son's Patent Drawing Review ( . s Amendment / Comment or in .84(c)) should be written on the he header according to 37 CFR	the Office action of drawings in the front (not the back) of 1.121(d).
attached Examiner's comment regarding REQUIREMENT		
Attachment(s) 1. ☑ Notice of References Cited (PTO-892)	5. Notice of Infor	mal Patent Application (PTO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Sum	mary (PTO-413),
3. Information Disclosure Statements (PTO-1449 or PTO/SB/C		ail Date nendment/Comment
Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiner's St	atement of Reasons for Allowance
of Biological Material	9. Other	

U.S. Patent and Trademark Office PTOL-37 (Rev. 7-05)

MICHAEL LEBENTRITT

SUPERVISORY PATENT EXAMINER

Application/Control Number: 10/710,001

Art Unit: 2812

## **REASONS FOR ALLOWANCE**

The following is an examiner's statement of reasons for allowance:

The closest prior art of record, Sato et al., US Patent 6,798,038, alone or in combination thereof, fails to show the following steps of:

Pertaining to independent claims 1 and 10, "depositing a single deposition step an isolation insulator layer in said isolation apertures to a depth sufficient to fill said isolation apertures above said device layer by a first margin that is less than the thickness of said pad insulator..." and "etching said pad insulator layer with an etchant that does not attack said isolation insulator layer, whereby said pad insulator and said remaining portion of said isolation insulator layer are removed in the same step and said isolation plugs fill said apertures without CMP."

Pertaining to independent claim 19, "etching said isolation insulator layer such that said sidewall thickness of said isolation insulator on said isolation aperture walls is removed and remaining isolation plugs of said insulator layer fill said apertures substantially coplanar with said device layer, without CMP" and "etching said pad insulator layer with an etchant that does not attack said isolation insulator layer, whereby said pad insulator and said remaining portion of said isolation insulator layer are removed in the same step and said isolation plugs fill said apertures without CMP."

Pertaining to independent claim 21, "...performing before said step of forming set of apertures in areas of pad insulator..."

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Allowance."

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stanetta D. Isaac whose telephone number is 571-272-1671. The examiner can normally be reached on Monday-Friday 9:30am -6:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Lebentritt can be reached on 571-272-1873. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Stanetta Isaac Patent Examiner February 17, 2006

MICHAEL LEBENTRIT SUPERVISORY PATENT EXAMINER